



Russell Hudyma Joins Cymer's Scientific Advisory Board

SAN DIEGO--(BUSINESS WIRE)--Oct. 6, 2003--Cymer Inc. (Nasdaq NM: CYMI), the world's leading supplier of excimer light sources used in semiconductor manufacturing, today announced that leading optics expert, Russell Hudyma, managing partner of Hyperion Development, LLC has joined Cymer's Scientific Advisory Board (SAB). The board reviews Cymer's advanced, next-generation research and development programs and helps guide the development of leading-edge technology solutions for the semiconductor industry.

"We are delighted that Russ has joined our Scientific Advisory Board. His outstanding experience in advanced design, analysis and modeling of lithographic optical systems makes him a vital contributor to our SAB," noted Bob Akins, Cymer's chairman and chief executive officer.

Established in 1999, Cymer's SAB is chartered with assisting Cymer in shaping the scope and direction of the company's technology roadmap and helping to prioritize Cymer's product development in alignment with the needs of the semiconductor industry and the ongoing demands of Moore's law. Hudyma's talents enhance an exceptionally talented board of industry-leading lithography experts, including Bob Akins, Ph.D., chairman, Rick Sandstrom, Ph.D., chief technology officer of Cymer, Nigel Farrar, Ph.D., Cymer fellow, William Partlo, Ph.D., Sr. Cymer fellow, Tony Yen, senior vice president of lithography market development of Cymer, Joseph Langston, retired department manager, advanced lithography of Intel, William Oldham, Ph.D., professor of electrical engineering and computer science at the University of California-Berkeley and Steef Wittekoek, Ph.D., executive scientist, ASML, retired.

Hudyma holds both a bachelor's and a master's degree in optics from the University of Rochester. In addition, Hudyma has published more than 20 papers on microlithography and related topics, holds or has applied for more than 30 U.S. and foreign patents, and teaches a popular SPIE short course entitled, "Optical Design in the Ultraviolet."

About Cymer

Cymer Inc. is the world's leading supplier of excimer laser illumination sources, the essential light source for deep ultraviolet (DUV) photolithography systems. DUV lithography is a key enabling technology, which has allowed the semiconductor industry to meet the exacting specifications and manufacturing requirements for volume production of today's advanced semiconductor chips. Further information on Cymer may be obtained from the company's SEC filings, on the Internet at www.cymer.com or by contacting the company directly.

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